

Special Issue

Innovations in Condition Monitoring, Optimization and Advanced Control for Complex Industrial Processes

Message from the Guest Editors

This Special Issue aims to provide a platform for discussion, an exchange of ideas and experiences, and the presentation of solutions for scientists and engineers dealing with industrial processes in the broadest sense, with special emphasis on condition monitoring, control, and optimisation.

Guest Editors

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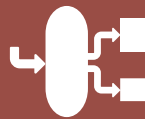
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Deadline for manuscript submissions

closed (1 December 2024)



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